## DOCKET NO: 263787US2PCT

## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

HIROSHI MASHIMA, ET AL. : EXAMINER: STOUFFER, KELLY

SERIAL NO: 10/518,371

FILED: DECEMBER 28, 2004 : GROUP ART UNIT: 1792

FOR: METHOD FOR PLASMA-ENHANCED CHEMICAL VAPOR DEPOSITION AND APPARATUS FOR PLASMA-ENHANCED CHEMICAL

VAPOR DEPOSITION

## AMENDMENT

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated August 5, 2008, please amend the aboveidentified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.